FIG. 1

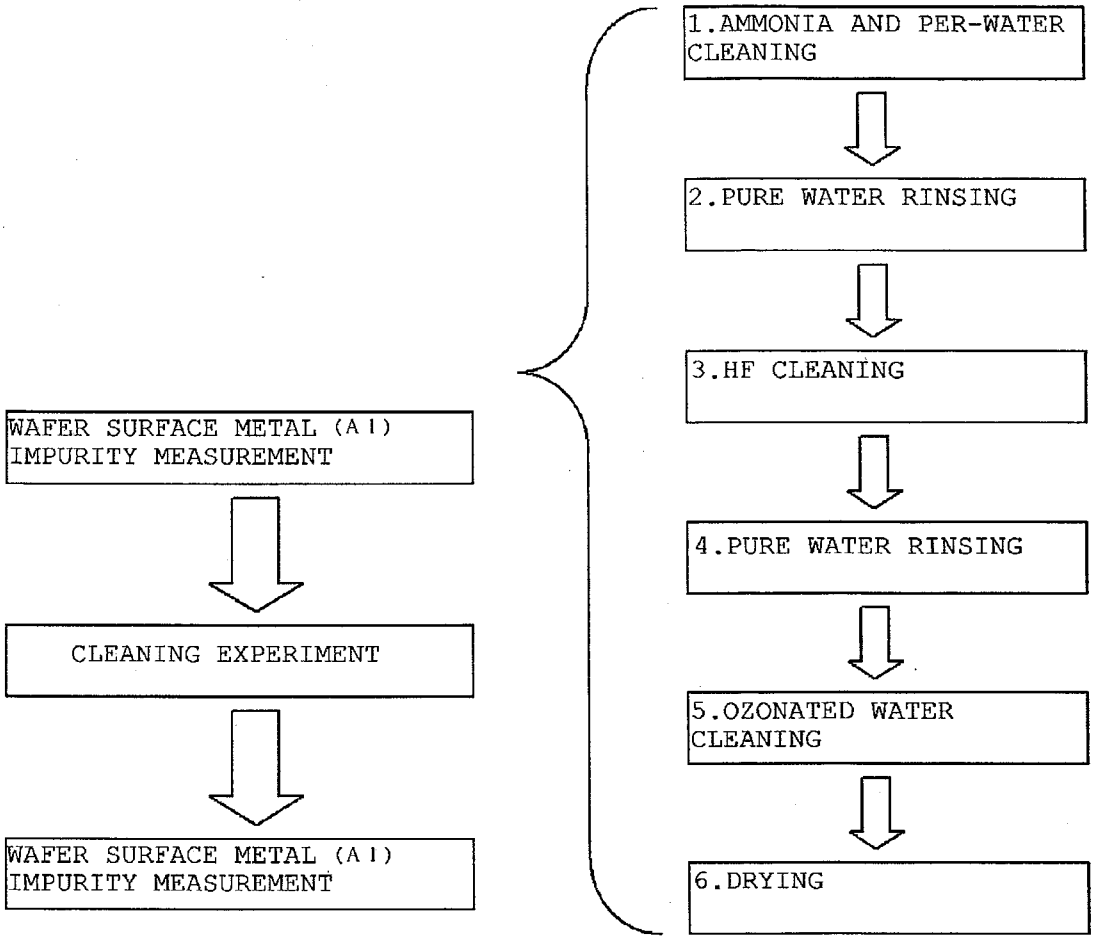

WAFER SURFACE METAL (Al) IMPURITY MEASUREMENT
CLEANING EXPERIMENT
WAFER SURFACE METAL (Al) IMPURITY MEASUREMENT
1.AMMONIA AND PER-WATER CLEANING
2.PURE WATER RINSING
3.HF CLEANING
4.PURE WATER RINSING
5.OZONATED WATER CLEANING
6.DRYING

FIG. 2

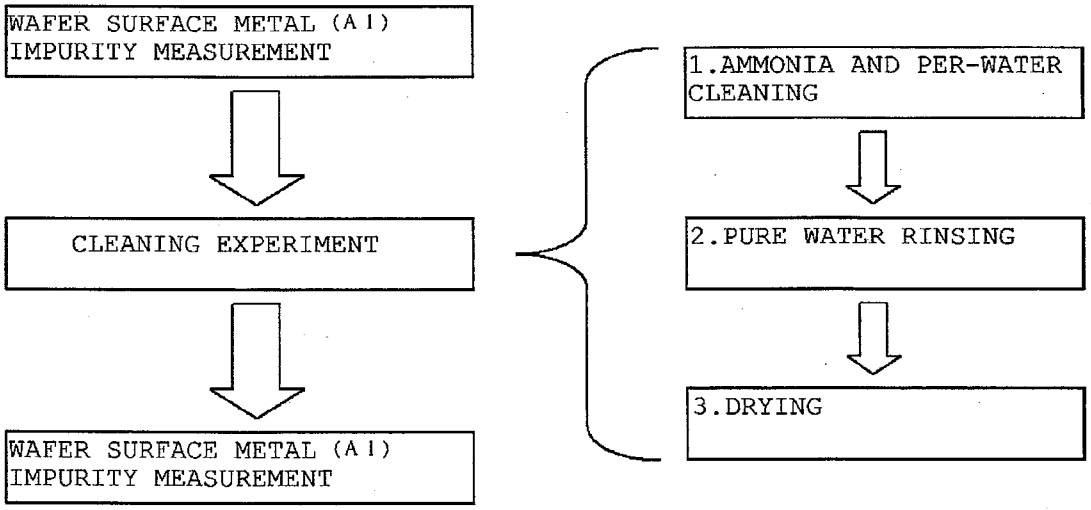

WAFER SURFACE METAL (Al) IMPURITY MEASUREMENT
CLEANING EXPERIMENT
WAFER SURFACE METAL (Al) IMPURITY MEASUREMENT
1.AMMONIA AND PER-WATER CLEANING
2.PURE WATER RINSING
3.DRYING

FIG. 3

